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**TRANSMITTAL LETTER TO THE UNITED STATES
DESIGNATED/ELECTED OFFICE (DO/EO/US)**

1265-01

09/890926INTERNATIONAL APPLICATION NO.
PCT/JP00/08356INTERNATIONAL FILING DATE
28 November 2000 (28.11.00)PRIORITY DATE CLAIMED
09 December 1999 (09.12.99)TITLE OF INVENTION PHOTSENSITIVE RESIN PRINT PLATE MATERIAL AND PRODUCTION METHOD FOR
PHOTSENSITIVE RESIN PRINT PLATE

APPLICANT(S) FOR DO/EO/US

Shinji Tanaka and Katsuhiko Uehara

Applicant herewith submits to the United States Designated/Elected Office (DO/EO/US) the following items under 35 U.S.C. 371:

1. ☒ This express request to immediately begin national examination procedures (35 U.S.C. 371(f)).
2. ☒ The U.S. National Fee (35 U.S.C. 371(c)(1)) and other fees as follows:

CLAIMS	(1) FOR	(2) NUMBER FILED	(3) NUMBER EXTRA	(4) RATE	(5) CALCULATIONS
	TOTAL CLAIMS	12 -20=	0	x \$18.00	\$
	INDEPENDENT CLAIMS	3 -3=	0	x \$80.00	
	MULTIPLE DEPENDENT CLAIM(S) (if applicable)			+ \$270.00	270.00
	BASIC NATIONAL FEE (37 CFR 1.492(a)(1)-(4)):				
	<input type="checkbox"/> International preliminary examination fee paid to USPTO (37 CFR 1.482).....\$690.00				
	<input type="checkbox"/> No international preliminary examination fee paid to USPTO (37 CFR 1.482) but international search fee paid to USPTO (37 CFR 1.445(a)(2)).....\$710.00				
	<input type="checkbox"/> Neither international preliminary examination fee (37 CFR 1.482) nor international search fee (37 CFR 1.445(a)(2)) paid to USPTO.....\$1,000.00				
	<input type="checkbox"/> International preliminary examination fee paid to USPTO (37 CFR 1.482) and all claims satisfied provisions of PCT Article 33(2) to (4).....\$ 100.00				
	<input checked="" type="checkbox"/> International Search Report enclosed\$860.00				860.00
	Surcharge of \$ _____ for furnishing the National fee or oath or declaration later than <input type="checkbox"/> 20 <input type="checkbox"/> 30 mos. from the earliest claimed priority date (37 CFR 1.482(e)).				\$130.00
	TOTAL OF ABOVE CALCULATIONS				1,130.00
	Reduction by ½ for filing by small entity, if applicable. Affidavits must be filed also. (Note 37 CFR 1.9, 1.27, 1.28.)				
	SUBTOTAL				1,130.00
	Processing fee of \$ _____ for furnishing the English Translation later than <input type="checkbox"/> 20 <input type="checkbox"/> 30 mos. from the earliest claimed priority date (37 CFR 1.482(f)).				\$130.00
	TOTAL NATIONAL FEE				1,130.00
	Fee for recording the enclosed assignment (37 CFR 1.21(h)).				\$40.00 40.00
	TOTAL FEES ENCLOSED				1,170.00

- a. ☒ A check in the amount of \$1,170.00 to cover the above fees is enclosed.
- b. ☐ Please charge my Deposit Account No. 13-3405 in the amount of \$ _____ to cover the above fees.
A duplicate copy of this sheet is enclosed.
- c. ☒ The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment to Deposit Account No. 13-3405. A duplicate copy of this sheet is enclosed.

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3. A copy of the International Application as filed (35 U.S.C. 371(c)(2))
- a. ☐ is transmitted herewith (required only if not transmitted by the International Bureau).
 - b. ☐ is not required, as the application was filed in the United States Receiving Office (RO/US).
 - c. ☒ has been transmitted by the International Bureau.
4. ☒ A translation of the International Application into English (35 U.S.C. 371(c)(2)).
5. Amendments to the claims of the International Application under PCT Article 19 (35 U.S.C. 371(c)(3))
- a. ☐ are transmitted herewith (required only if not transmitted by the International Bureau).
 - b. ☐ have been transmitted by the International Bureau.
6. ☐ A translation of the amendments to the claims under PCT Article 19 (35 U.S.C. 371(c)(3)).
7. ☒ An oath or declaration of the inventor (35 U.S.C. 371(c)(4)).
8. ☐ A translation of the Annexes to the International Preliminary Examination Report under PCT Article 36 (35 U.S.C. 371(c)(5)).

Other document(s) or information included:

9. ☐ An Information Disclosure Statement under 37 C.F.R. 1.97 and 1.98.
10. ☒ An Assignment document for recording and a Recordation Form Cover Sheet - Patents Only. Please mail the recorded assignment document to the person whose signature, name and address appears at the bottom of this page.

1. The above checked items are being transmitted
- a. ☐ before the 18th month publication.
 - b. ☒ after publication and the Article 20 communication but before 20 months from the priority date.
 - c. ☐ after 20 months but before 22 months (surcharge and/or processing fee included).
 - d. ☐ after 22 months (surcharge and/or processing fee included).

Note: Petition to revive (37 C.F.R. 1.137(a) or (b)) is necessary if 35 U.S.C. 371 requirements submitted after 22 months and no proper demand for International Preliminary Examination was made by 19 months from the earliest claimed priority date.

- e. ☐ by 30 months and a proper demand for International Preliminary Examination was made by the 19th month from the earliest claimed priority date.
- f. ☐ after 30 months but before 32 months and a proper demand for International Preliminary Examination was made by the 19th month from the earliest claimed priority date (surcharge and/or processing fee included).
- g. ☐ after 32 months (surcharge and/or processing fee included).

Note: Petition to revive (37 C.F.R. 1.137(a) or (b)) is necessary if 35 U.S.C. 371 requirements submitted after 32 months and a proper demand for International Preliminary Examination was made by 19 months from the earliest claimed priority date.

12. At the time of transmittal, the time limit for amending claims under Article 19
- a. ☐ has expired and no amendments were made.
 - b. ☐ has not yet expired.
13. ☐ Certain requirements under 35 U.S.C. 371 were previously submitted by the applicant on _____, namely:

SCHNADER HARRISON SEGAL & LEWIS

Date: 7 AUG 2001

By: T. Daniel Christenbury

T. Daniel Christenbury, Reg. No. 31,750
1600 Market Street, 36th Floor
Philadelphia, PA 19103

DESCRIPTION

PHOTOSENSITIVE RESIN PRINT PLATE MATERIAL AND PRODUCTION METHOD
FOR PHOTOSENSITIVE RESIN PRINT PLATE

TECHNICAL FIELD

The present invention relates to a photosensitive resin printing plate material capable of forming a photosensitive resin printing plate with relief thereon, and to a method for producing such a photosensitive resin printing plate from the material. The photosensitive resin printing plate thus produced is usable for relief printing and flexographic printing plates.

BACKGROUND ART

Use of photosensitive resin compositions for printing plate materials is known, and it is the main stream in the art of relief printing, lithographic printing, intaglio printing and flexographic printing.

With its photosensitive resin layer being contacted with a negative or positive original picture film, the printing plate material of the type is exposed to activated rays through the original picture film so as to form a solvent-soluble part and a solvent-insoluble part in its photosensitive resin layer, and then processed into a printing plate having a relief image

thereon.

The printing plate material thus requires a negative or positive original picture film and requires development. Therefore, for forming one printing plate from it, the material requires many steps and much labor.

With the recent progress in computerization, proposed are methods of directly outputting the information having been processed by computer onto a printing plate material followed by processing the resulting material into a relief or flexographic printing plate not requiring a step of preparing an original picture film for it.

Concretely, proposed are (1) a method of forming an image on a photosensitive resin layer or on a thin film layer provided on a photosensitive resin layer, with toner or liquid ink, not requiring an original picture film (Japanese Patent Publication No. 20029/1983, Japanese Patent Laid-Open Nos. 110164/1991, 10709/1998, 10710/1998); (2) a method of directly obtaining a printing plate by exposing a porous material or a photosensitive layer to laser rays followed by dissolving or subliming the exposed part (Japanese Patent Laid-Open Nos. 56601/1977, 127005/1978, Japanese Patent Publication No. 40033/1981, Japanese Patent Laid-Open No. 106249/1986, International Patent Publication Nos. 505840/1995, 506780/1995, Japanese Patent Laid-Open Nos. 99478/1996, 90947/1996, 142050/1997, 254351/1997); (3) a method of forming a pattern on an IR-

sensitive layer provided on the surface of a photosensitive resin layer, by exposing it to laser rays, not requiring an original picture film (Japanese Patent Laid-Open No. 52646/1983, Japanese Patent Nos. 2,773,847, 2,773,981, International Patent Publication No. 509254/1998, Japanese Patent Laid-Open Nos. 305007/1996, 305030/1996. 171247/1997, 166875/1997, 39512/1998, 39512/1998, 73917/1998).

The method (1) is requires toner or liquid ink for image formation, it is problematic in that fine images could not be formed therein. In the method (2), a porous material or a photosensitive layer is exposed to high-energy laser rays, and therefore it is problematic in that sharp images are difficult to obtain therein since the relief edges of the porous material and the photosensitive layer melt down. In the method (3), the IR-sensitive layer formed is not transparent, and therefore it is problematic in that the photosensitive resin printing plate processed therein is difficult to inspect. In this, even though the layer is transparent in some degree, it is still problematic in that its UV-blocking ability is unsatisfactory.

In view of the above-mentioned problems, the present invention is to propose a photosensitive resin printing plate material which is transparent to accept virtual inspection and which can form an image thereon through exposure to light having a wavelength of from 450 to 1500 nm. Concretely, through the step of image formation thereon, the material enables a

difference between the UV-transmissive site and the UV-non-transmissive site thereof to thereby reproduce even fine relief thereon, not requiring an original picture film.

DISCLOSURE OF THE INVENTION

Solving the above-mentioned problems, the essential constitution of the invention is as follows.

Specifically, the photosensitive resin printing plate material of the invention comprises at least a support, a photosensitive resin layer and a photocoloring layer, in which the photocoloring layer is UV-transmissive before colored, and is colored through exposure to light having a wavelength of from 450 to 1500 nm to be substantially UV-non-transmissive.

The essential constitution of the method for producing a photosensitive resin printing plate of the invention is as follows. Specifically, the method comprises at least a step of forming an image in a photocoloring layer, a step of exposing a photosensitive resin layer to light through the photocoloring layer, and a step of developing the photosensitive resin layer.

BEST MODES OF CARRYING OUT THE INVENTION

The photosensitive resin printing plate material of the invention comprises a support, a photosensitive resin layer and a photocoloring layer.

The layers are described in detail hereinafter.

The support in the invention is made of a metal sheet of steel, stainless, aluminium, etc., or a plastic sheet of polyester, etc., or a synthetic rubber sheet of styrene-butadiene rubber, etc. Its thickness is determined depending on its use, but may generally fall between 50 and 1000 μm .

Preferably, an adhesive layer is provided on the support for enhancing the adhesiveness between the support and the photosensitive resin layer. Though varying depending on the type of the support, generally used is a polyester adhesive or epoxy adhesive for the adhesive layer. Preferably, the thickness of the adhesive layer falls between 0.5 and 40 μm .

The photosensitive resin layer in the invention is photocurable through exposure to light. Preferably, it is photocurable through exposure to light having a wavelength of from 300 to 450 nm. The photosensitive resin layer is in the form of a sheet of a photosensitive resin composition, preferably having a thickness of from 0.1 to 10 mm.

Preferably, the photosensitive resin composition contains at least an ethylenic unsaturated monomer and a photo-polymerization initiator.

The ethylenic unsaturated monomer is a substance crosslinkable through radical polymerization. It is not specifically defined, provided that it is crosslinkable through radical polymerization. In general, it includes the following: Compounds having only one ethylenic unsaturated

bond, for example, hydroxyl group-having (meth)acrylates such as 2-hydroxyethyl (meth)acrylate, 2-hydroxypropyl (meth)acrylate, 2-hydroxybutyl (meth)acrylate, 3-chloro-2-hydroxypropyl (meth)acrylate, β -hydroxy- β' -(meth)acryloyloxyethyl phthalate, etc., alkyl (meth)acrylates such as methyl (meth)acrylate, ethyl (meth)acrylate, propyl (meth)acrylate, butyl (meth)acrylate, isoamyl (meth)acrylate, 2-ethylhexyl (meth)acrylate, lauryl (meth)acrylate, stearyl (meth)acrylate, etc., cycloalkyl (meth)acrylates such as cyclohexyl (meth)acrylate, etc., halogenoalkyl (meth)acrylates such as chloroethyl (meth)acrylate, chloropropyl (meth)acrylate, etc., alkoxyalkyl (meth)acrylates such as methoxyethyl (meth)acrylate, ethoxyethyl (meth)acrylate, butoxyethyl (meth)acrylate, etc., phenoxyalkyl (meth)acrylates such as phenoxyethyl acrylate, nonylphenoxyethyl (meth)acrylate, etc., alkoxyalkylene glycol (meth)acrylates such as ethoxydiethylene glycol (meth)acrylate, methoxytriethylene glycol (meth)acrylate, methoxydipropylene glycol (meth)acrylate, etc., (meth)acrylamides such as (meth)acrylamide, diacetone(meth)acrylamide, N,N'-methylenebis(meth)acrylamide, etc., as well as 2,2-dimethylaminoethyl (meth)acrylate, 2,2-diethylaminoethyl (meth)acrylate, N,N-dimethylaminoethyl(meth)acrylamide, N,N-dimethylaminopropyl(meth)acrylamide, 2-hydroxyethyl

(meth)acrylate, 3-chloro-2-hydroxypropyl (meth)acrylate, etc.; and compounds having two or more ethylenic unsaturated bonds, for example, polyethylene glycol di(meth)acrylates such as diethylene glycol di(meth)acrylate, etc., polypropylene glycol di(meth)acrylates such as dipropylene glycol di(meth)acrylate, etc., trimethylolpropane tri(meth)acrylate, pentaerythritol tri(meth)acrylate, pentaerythritol tetra(meth)acrylate, glycol tri(meth)acrylate, poly(meth)acrylates obtained through addition reaction of ethylene glycol diglycidyl ether with a compound having an ethylenic unsaturated bond and an active hydrogen of, for example, unsaturated carboxylic acids or unsaturated alcohols, poly(meth)acrylates obtained through addition reaction of an unsaturated epoxy compound, e.g., glycidyl (meth)acrylate with a compound having an active hydrogen of, for example, carboxylic acids or amines, poly(meth)acrylamides such as methylenebis(meth)acrylamide, etc., polyvinyl compounds such as divinylbenzene, etc.

The photo-polymerization initiator is not specifically defined, provided that it has the ability to initiate the polymerization of photo-polymerizable carbon-carbon unsaturated groups. Above all, preferred for use herein are those capable of absorbing light to form a radical through autolysis or hydrogen pull reaction. For example, they include benzoin alkyl ethers, benzophenones, anthraquinones, benzils,

acetophenones, diacetyls, etc.

Preferably, the photosensitive resin composition for use in the invention contains a carrier resin in order that it can be solid and can keep the shape of its layer. In general, the type of the carrier resin to be in the resin composition varies, depending on the type of the ink to be applied to the printing plates that comprise a layer of the resin composition. For the printing plates for aqueous ink, the carrier resin may be ordinary rubber or elastomer, including, for example, butadiene rubber, nitrile rubber, urethane rubber, isoprene rubber, styrene-butadiene rubber, styrene-isoprene rubber, etc. For those for oily ink, it may be hydrophilic resin, including, for example, partially-saponified vinyl acetate, polyamide resin, polyvinyl alcohol, as well as their modified derivatives such as maleic acid-modified derivatives, succinic acid-modified derivatives, epoxy-modified derivatives, e.g., glycidyl methacrylate-modified derivatives, etc.

In addition, the photosensitive resin composition may contain any other components. For example, it may contain, as a compatibilizer for enhancing the compatibility of the constituent ingredients and the flexibility of the resin layer, a polyalcohol such as ethylene glycol, diethylene glycol, triethylene glycol, glycerin, trimethylolpropane or trimethylolethane, or liquid rubber such as liquid polybutadiene or liquid polyisoprene, and may contain a known

polymerization inhibitor for enhancing the heat stability of the resin layer. Preferred examples of the polymerization inhibitor are phenols, hydroquinones, and catechols. The photosensitive resin composition may further contain dye, pigment, surfactant, UV absorbent, fragrance, antioxidant, etc.

For forming a layer of the photosensitive resin composition that contains a carrier resin, herein employed is a method that comprises dissolving a carrier resin in a solvent for the resin, then adding thereto an ethylenic unsaturated monomer and a photo-polymerization initiator, fully stirring them to prepare a solution of a photosensitive resin composition, then removing the solvent from the solution, and finally extruding a melt of the resulting resin composition onto a support coated with an adhesive.

The photocoloring layer in the invention is UV-transmissive before colored, and is colored through exposure to light having a wavelength of from 450 to 1500 nm to be substantially UV-non-transmissive.

UV-transmission through the layer can be determined on the basis of the optical density of the layer. The optical density is generally designated by D , and is defined by the following equation.

$$D = \log_{10} O = \log_{10} (1/T) = \log_{10} (I_0/I)$$

wherein $O = I_0/I$ indicates the photographic density of the layer,

T indicates the transmittance thereof, I_0 indicates the intensity of the light applied to the layer for measurement of the transmittance, and I indicates the intensity of the transmitted light.

For determining the optical density, known are a method of measuring the intensity of the transmitted light and a method measuring the intensity of the incident light. In the invention, the optical density is determined on the basis of the intensity of the transmitted light.

Concretely, for example, the optical density can be measured with a Macbeth transmission densitometer TR-927 (from Kollmorgen Instruments Corporation), using an orthomatic filter.

In the invention, UV-transmission means that the optical density of the layer is at most 0.5, and substantial UV-non-transmission means that the optical density of the layer is at least 1.5.

The photocoloring layer includes two cases; (1) it contains at least a photothermal-transforming substance, a thermal color former and a developer all in one, or (2) it comprises at least a layer that contains a photothermal-transforming substance and a layer that contains a thermal color former and a developer.

The photothermal-transforming substance is a compound that absorbs light having a wavelength of from 450 to 1500 nm

and generates heat. Concretely, it includes black pigments such as carbon black, titanium black, aniline black, cyanine black, etc.; green pigments such as phthalocyanine-type or naphthalocyanine-type pigments, etc.; carbon graphite, diamine-type metal complexes, dithiol-type metal complexes, phenolthiol-type metal complexes, mercaptophenol-type metal complexes, crystal water-containing inorganic compounds, copper sulfate, chromium sulfide, silicates, as well as metal oxides such as titanium oxide, vanadium oxide, manganese oxide, iron oxide, cobalt oxide, tungsten oxide, etc., and hydroxides and sulfates of such metals, etc.

Of those, preferred for the photothermal-transforming substance for use herein are colorants, especially dyes capable of absorbing IR or near-IR rays, in view of their light transmittance within a wavelength range of from 300 nm to 450 nm and of their transparency. Of the colorants of the type, more preferred are cyanine compounds, phthalocyanine compounds, naphthalocyanine compounds, dithiol metal complexes, biazulenium compounds, squarylium compounds, croconium compounds, azo-type disperse dyes, bisazo compounds, bisazostilbene compounds, naphthoquinone compounds, anthraquinone compounds, perylene compounds, polymethine compounds, indaniline metal complex dyes, intermolecular CT compounds, benzothiopyran compounds, spiropyran compounds, nigrosine compounds, thioindigo compounds, nitroso compounds,

light absorbance.

Preferably, the photothermal-transforming substance content of the photocoloring layer composition falls between 1 and 40 % by weight, more preferably between 2 and 25 % by weight of the solid content of the composition. Containing at least 1 % by weight of the substance, the layer effectively absorbs laser rays. Containing at most 40 % by weight of the substance, the physical properties of the photocoloring layer composition is not influenced by the substance.

The thermal color former is a compound capable of forming a color when heated. For this, any known compound is usable herein so far as it has the function of forming a color under heat. Preferred are leuco compounds, concretely including triphenylmethanephthalide-type, triallylmethane-type, phenothiazine-type, thiophenyloran-type, xanthene-type, indophthalyl-type, spirofuran-type, azaphthalide-type, chromenopyrazole-type, methine-type, rhodamine-anilinolactam-type, rhodamine-lactam-type, quinazoline-type, diazoxanthene-type and bislactone-type compounds.

The thermal color former content of the photocoloring layer is not specifically defined, as it varies depending on the optical density of the colored layer. Preferably, however, it falls between 0.1 and 30 % by weight, more preferably between 0.5 and 20 % by weight of the solid content of the photocoloring layer

the optical density of the colored layer. Preferably, however, it falls between 0.1 and 30 % by weight, more preferably between 0.5 and 20 % by weight of the solid content of the photocoloring layer composition. Containing such a thermal color former in an amount of at least 0.1 % by weight, the layer can have the necessary optical density after processed for color formation therein. Containing it in an amount of at most 30 % by weight, the mechanical strength of the layer does not lower. The defined range of the thermal color former content is therefore preferred for these reasons.

The developer is not specifically defined, so far as it has the ability to assist the color formation from the thermal color former. For example, it includes phenolic compounds, thiophenolic compounds, thiourea derivatives, organic acids and their metal salts, dibasic acids, organic phosphate compounds, etc.

Preferably, the developer content of the photocoloring layer composition falls between 0.1 and 50 % by weight of the solid content of the composition. The developer, if in the layer in an amount of at least 0.1 % by weight, well exhibits its effect to assist the color formation from the thermal color former therein. Containing it in an amount of at most 50 % by weight, the mechanical strength of the photocoloring layer does not lower. The defined range of the developer content is therefore preferred for these reasons.

The photocoloring layer composition generally contains a carrier resin. The resin is not specifically defined, including, for example, the following: polyvinyl alcohol, polyvinyl acetate, partially-saponified polyvinyl acetate, cellulose resin, acrylic resin, polyvinylpyrrolidone, nylon resin, urethane resin, ethylene-vinyl acetate copolymer, polybutadiene, polyisoprene, styrene-butadiene rubber, nitrile rubber, etc. However, these are not limitative.

Preferably, the carrier resin content of the photocoloring layer composition falls between 20 and 99 % by weight, more preferably between 30 and 60 % by weight of the solid content of the composition. Containing such a carrier resin in an amount of at least 20 % by weight, the photocoloring layer can keep its shape. The carrier resin in the layer in an amount of at most 99 % by weight does not have any negative influence of the optical density of the layer.

If desired, the photocoloring layer may further contain an additional ingredient, plasticizer. The plasticizer includes, for example, glycols such as ethylene glycol, diethylene glycol, triethylene glycol, etc.; polyalkylene glycols such as polyethylene glycol, polypropylene glycol, etc.; liquid rubber such as liquid polybutadiene, liquid isoprene rubber.

The thickness of the photocoloring layer is not specifically defined, so far as the optical density of the

colored layer is enough for use herein. Its preferred range falls between 0.1 μm and 30 μm . Having a thickness of at least 0.1 μm , the colored layer can well block UV transmission through it. In the layer not thicker than 30 μm , the UV absorption by the carrier resin is reduced. The defined range of the layer thickness is therefore preferred for these reasons.

If desired, a protective film may be provided on the uppermost layer of the printing plate material of the invention. For the protective film, usable is any film of polyethylene terephthalate, polybutylene terephthalate, polyethylene, polypropylene, etc. Preferably, the film has a thickness falling between 5 μm and 150 μm . The film not thinner than 5 μm well serve as a protective film. Not thicker than 150 μm , the protective film is flexible and is easy to peel. The defined range of the film thickness is therefore preferred for these reasons.

Also if desired, a release layer may be provided between the protective film and the photocoloring layer. The release layer makes it possible to peel only the protective film via it. Its material is not specifically defined, so far as it facilitates the release of the protective layer. For example, it includes polyvinyl alcohol, polyvinyl acetate, partially-saponified polyvinyl acetate, cellulose resin, acrylic resin, polyvinylpyrrolidone, nylon resin, urethane resin, ethylene-vinyl acetate copolymer, polybutadiene,

polyisoprene, styrene-butadiene rubber, nitrile rubber, polyester resin. However, these are not limitative.

Still if desired, a substance transfer-preventing layer may be provided between the photosensitive resin layer and the photocoloring layer. This is for preventing the photothermal-transforming substance, the color former and the developer existing in the photocoloring layer and also the substances existing in the photosensitive resin layer from transferring. The material for the layer is not specifically defined, so far as it has the ability to prevent the substances from transferring into the other layers, especially into the photosensitive resin layer. Some examples of the material are mentioned below.

For the substance transfer-preventing layer, usable is a binder resin selected from water-soluble resins, hydrophobic resins and UV-curable resins. In case where the carrier resin in the photosensitive resin layer is a water-soluble resin such as partially-saponified polyvinyl acetate or water-soluble nylon resin, hydrophobic resins and UV-curable resins are preferred for the substance transfer-preventing layer as their effect is good. On the other hand, in case where the carrier resin in the photosensitive resin layer is a hydrophobic resin such as butadiene rubber or styrene-isoprene rubber, water-soluble resins and UV-curable resins are preferred for the substance transfer-preventing layer as their effect is good.

Concretely, the water-soluble resins include polyvinyl alcohol, partially-saponified polyvinyl acetate (having a degree of saponification of at least 90 %), cellulose resin, acrylic resin, polyvinylpyrrolidone, nylon resin, and their modified derivatives. The hydrophobic resins include partially-saponified polyvinyl acetate (having a degree of saponification of smaller than 90 %), nylon resin, polyvinyl acetate, urethane resin, ethylene-vinyl acetate copolymer, polybutadiene, polyisoprene, styrene-butadiene rubber, nitrile rubber, polyester resin, as well as polyethylene terephthalate, polypropylene, polyethylene, etc.

The UV-curable resins are meant to indicate a composition that comprises an ethylenic unsaturated compound or an ethylenic group-having oligomer along with a photopolymerization initiator and can be polymerized through exposure to UV rays into a resinous material. If desired, the UV-curable resin of the type may be combined with any of the above-mentioned water-soluble resins or hydrophobic resins. For example, the ethylenic unsaturated compound includes 2-hydroxyethyl (meth)acrylate, methyl (meth)acrylate, cyclohexyl (meth)acrylate, methoxyethyl (meth)acrylate, etc. The ethylenic group-having oligomer includes urethane acrylates, epoxy acrylates, acryl-modified liquid butadiene rubbers, etc. The photopolymerization initiator includes benzoin alkyl ethers, benzophenones, anthraquinones, etc.

The thickness of the substance transfer-preventing layer is not specifically defined, so far as the layer is effective for blocking substances. Preferably, however, it falls between 0.5 and 20 μm . Having a thickness of at least 0.5 μm , the layer well exhibits its effect to prevent substances from moving. Having a thickness of at most 20 μm , the layer is good since the relief image of the colored layer can be substantially equal to the relief image of the photosensitive resin layer formed through exposure to UV rays via the colored layer.

For producing the photosensitive resin printing plate material of the invention, for example, a solution of a photocoloring layer composition dissolved in a solvent is applied to the photosensitive resin layer formed on a support, using a bar coater, a slit die coater, a gravure coater, a comma coater, a reverse coater or the like, and then dried. In case where a protective film is provided on the photocoloring layer, it is first coated with a photocoloring layer composition, using a coater such as that mentioned above, and dried to form thereon a photocoloring layer having a predetermined thickness, and then the thus-coated protective film is hermetically fitted to the photosensitive layer formed on a support, using a roller. In that manner, the photosensitive resin printing plate material produced has a protective film formed on the photocoloring layer thereof.

In case where a substance transfer-preventing layer is

provided in the printing plate material, for example, a binder resin to be the layer is dissolved in a solvent, and the resulting solution is applied onto the photosensitive resin layer, using a bar coater, a slit die coater, a gravure coater, a comma coater, a reverse coater or the like, and thereafter a photocoloring layer is formed on the thus-formed, substance transfer-preventing layer according to the method mentioned above. In case where both a protective layer and a substance transfer-preventing layer are provided on and in the printing plate material, for example, a photocoloring layer composition is first formed on a protective film in the manner mentioned above, then a solution of a binder resin to be the substance transfer-preventing layer is applied onto the photocoloring layer also in the manner mentioned above and optionally exposed to UV rays to thereby form the intended, substance transfer-preventing layer on the photocoloring layer, and finally the thus-coated protective film is hermetically fitted to the photosensitive resin layer formed on a support, using a roller.

The thus-produced, photosensitive resin printing plate material is processed into a photosensitive resin printing plate, for example, in the manner mentioned below.

The method for producing such a photosensitive resin printing plate of the invention is described hereinafter.

The method comprises at least a step of forming an image

in a photocoloring layer, a step of exposing a photosensitive resin layer to light through the image, and a step of developing the photosensitive resin layer.

More precisely, the method for producing a photosensitive resin printing plate is characterized in that a photosensitive resin printing plate material having a photosensitive resin layer and a photocoloring layer laminated on a support is imagewise exposed to light having a wavelength of from 450 to 1500 nm whereby only the exposed site of the photocoloring layer is colored to form an image in the layer, then this is further exposed to light having a wavelength of from 300 to 450 nm via the image-having, colored layer to thereby imagewise cure the photosensitive resin layer, and thereafter this is processed with a developer so as to remove the resin layer except the cured resin to thereby form a relief image on the support.

In the step of forming an image in the photocoloring layer, the layer is, if coated with a protective film, imagewise exposed to a light from a laser having a wavelength of from 450 to 1500 nm, through the protective film directly as it is or after the protective film has been peeled off, to thereby form an image in the thus-exposed, colored layer. In this step, the laser rays are absorbed by the photothermal-transforming substance in the photocoloring layer, and the part of the layer exposed to the laser rays is heated to have an elevated temperature. With that, the thermal color former in the layer

forms a color, and, as a result, the thus-colored layer does not substantially transmit UV rays. Through the process, the thus-exposed photocoloring layer has a colored region and a non-colored region, therefore having therein an image patterned by the combination of the two regions. For the laser exposure, used is any ordinary laser source. For example, usable for it are various lasers having an oscillation wavelength range of from 450 nm to 1500 nm, such as Ar ion lasers, Kr ion lasers, He-Ne lasers, He-Cd lasers, ruby lasers, glass lasers, semiconductor lasers, YAG lasers, titanium sapphire lasers, color lasers, nitrogen lasers, metal vapor lasers, etc. Of those, preferred are semiconductor lasers as they are technically much improved these days and are therefore more small-sized and more economical than the others.

In the next step of exposing the photosensitive resin layer through the photocoloring layer, the photosensitive resin printing plate material having been exposed to laser rays in the previous step is further exposed to light generally having a wavelength of from 300 nm to 450 nm, entirely on its surface via the image-formed, colored layer. In this step, since the colored region of the photocoloring layer having been exposed to laser rays in the previous step does not substantially transmit UV rays, the light of from 300 to 450 nm applied to the printing plate material does not reach the photosensitive resin layer of the material. Since the light applied to the

photosensitive resin printing plate material in this step will enter it even through the sides thereof, it is desirable that the sides of the printing plate material are protected with a cover not transmitting the light. For the source of light falling within a wavelength range of from 300 nm to 450 nm, generally employed is any of high-pressure mercury lamps, ultra-high-pressure mercury lamps, metal halide lamps, xenon lamps, carbon arc lamps, chemical lamps, etc. After thus exposed to the light, the part of the photosensitive resin layer forms a substance not dissolving in a developer.

In the step of developing the photosensitive resin layer, the layer having been exposed in the previous step is developed with a developer capable of dissolving and removing the non-exposed part of the layer, for which, for example, used is a brush washer or a spray washer provided with the developer of the type. Through the process, the exposed region of the photosensitive layer remains on the processed plate, therefore forming a relieve image thereon.

If desired, the thus-processed printing plate is dried, post-exposed and degummed. Thus produced, the printing plate is fitted in a printer.

EXAMPLES

The invention is described in detail with reference to the following Examples.

The layer compositions used in Examples, and the methods for producing them are described below.

(1) Photocoloring layer compositions:

Photocoloring layer composition 1:

The following ingredients were mixed at room temperature to give a uniform solution.

(a) Polyvinylpyrrolidone (ISP Japan's K-120)	40 wt.pts.
(b) Polymethine dye (Nippon Kayaku's KAYASORB IR820(B))	5 wt.pts.
(c) 3-(N-isoamyl-N-ethylamine)-7,8-benzofluoran	10 wt.pts.
(d) Octadecylphosphonic acid	30 wt.pts.
(e) Toluene	135 wt.pts.
(f) Methyl ethyl ketone	385 wt.pts.
(g) Methanol	100 wt.pts.
(h) Methyl cellosolve	200 wt.pts.

Photocoloring layer composition 2:

<Composition containing photothermal-transforming substance>

The following ingredients were mixed at room temperature to give a uniform solution.

(a) Polyvinylpyrrolidone (ISP Japan's K-120)	40 wt.pts.
(b) Polymethine dye (Nippon Kayaku's KAYASORB IR820(B))	5 wt.pts.

(c) Methyl ethyl ketone	250 wt.pts.
(d) Methanol	100 wt.pts.
(e) Methyl cellosolve	200 wt.pts.

<Composition containing thermal color former and developer>

The following ingredients were mixed at room temperature to give a uniform solution.

(a) 3-(N-isoamyl-N-ethylamine)-7,8-benzofluoran	10 wt.pts.
(b) Octadecylphosphonic acid	30 wt.pts.
(c) Vinyl chloride-vinyl acetate copolymer	30 wt.pts.
(d) Toluene	135 wt.pts.
(e) Methyl ethyl ketone	135 wt.pts.

(2) Photosensitive resin layer compositions:

Photosensitive resin layer composition 1:

60 parts by weight of a salt of α,ω -diaminopolyoxyethylene (this was prepared by adding acrylonitrile to both terminals of polyethylene glycol having a number-average molecular weight of 600, followed by reducing the resulting adduct with hydrogen) and adipic acid (1/1, by mol), 20 parts by weight of ϵ -caprolactam and 20 parts by weight of a salt of hexamethylenediamine and adipic acid (1/1, by mol) were polymerized in melt under ordinary condition to give a polyamide 1 having a relative viscosity (measured by dissolving 1 g of the polymer in 100 ml of chloral hydrate, at 25°C) of

Next, the following ingredients were mixed to give a photosensitive resin composition 1.

(b) Ethylenic unsaturated compound, i.e. adduct of glycidyl methacrylate (1 mol) and acrylic acid (1 mol)

(c) Polyadduct of propylene glycol diglycidyl ether (1 mol) and acrylic acid (2 mols) 15 wt.pts.

(e) Dimethylbenzyl ketal 1 wt.pt.

(g) Water 30 wt.pts.

(h) Ethanol 70 wt.pts.

Photosensitive resin layer composition 2:

Starting materials, i.e. 100 parts by weight of water, 0.2 parts by weight of sodium dodecylbenzenesulfonate, 3 parts by weight of polyoxyethylene nonylphenyl ether, 0.3 parts by weight of potassium persulfate, 0.2 parts by weight of t-dodecylmercaptan, 29 parts by weight of methyl methacrylate, 1 part by weight of methacrylic acid and 70 parts by weight of butadiene were reacted at 50°C for 20 hours to give an aqueous dispersion latex rubber 1 having a number-average particle size of 140 nm, a glass transition point of -52°C and a solid content of 50.5 % by weight.

Starting materials, i.e. 65 parts by weight of water, 1.3 parts by weight of disproportionated potassium rosinate, 1.7 parts by weight of potassium oleate, 1.5 parts by weight of sodium alkylsulfonate, 0.05 parts by weight of t-dodecylmercaptan, 0.1 parts by weight of paramenthane hydroperoxide, 0.003 parts by weight of iron sulfate, 0.006 parts by weight of sodium ethylenediaminetetraacetate, 0.005 parts by weight of sodium formaldehyde sulfoxylate, 1.2 parts by weight of potassium sulfate and 100 parts by weight of butadiene were reacted in a mode of low-temperature polymerization at 5°C. The degree of polymerization was about 60 %. Thus was obtained an aqueous dispersion latex rubber 2 having a number-average particle size of 350 nm and a solid content of 55 % by weight.

Next, the following ingredients were mixed under heat, and water was removed from the resulting mixture to give a photosensitive resin composition 2.

(a) Aqueous dispersion latex rubber 1

33.6 wt.pts. (17 wt.pts. in terms of the solid content)

(b) Aqueous dispersion latex rubber 2

14.5 wt.pts. (8 wt.pts. in terms of the solid content)

(c) Phenoxyethylene glycol acrylate

16 wt.pts.

(d) Polycondensate of glycerin polyether-polyol, succinic anhydride and 2-hydroxyethyl acrylate

	14 wt.pts.
(e) Polybutadiene rubber (Nippon Zeon's Nipol 1220L)	20 wt.pts.
(f) Nitrile rubber (Nippon Zeon's Nipol 1042)	20 wt.pts.
(g) Dimethylbenzyl ketal	1 wt.pt.
(h) Dioctyl phthalate	2 wt.pts.
(i) Hydroquinone monomethyl ether	0.1 wt.pts.
(3) Substance transfer-preventing layer composition:	
Substance transfer-preventing layer composition:	
(a) Partially-saponified polyvinyl acetate (having a degree of saponification of 95 % and a mean degree of polymerization of 1000)	100 wt.pts.
(b) Difunctional vinyl monomer obtained through addition reaction of ethylene glycol diglycidyl ether and acrylic acid	50 wt.pts.
(c) Benzoin ethyl ether	4 wt.pts.
(d) Water	90 wt.pts.
(e) Ethanol	210 wt.pts.

Example 1:

The photocoloring layer composition 1 was applied onto a protective film of polyethylene terephthalate having a thickness of 12 μm , using a bar coater, and dried to form thereon a photocoloring layer having a thickness of 10 μm . Thus coated, the film was transparent and green. Its optical density was

0.4. The substance transfer-preventing layer composition 1 was applied thereonto, using a bar coater, then dried, and exposed to an ultra-high-pressure mercury lamp for 30 seconds. Thus photocured, the substance transfer-preventing layer formed had a thickness of 8 μm .

Next, the photosensitive resin layer composition 1 was cast onto a support film of polyethylene terephthalate (thickness: 250 μm) coated with a polyester adhesive, and dried at 60°C for 3 hours to form a photosensitive resin layer having a dry thickness of 650 μm .

The support film thus coated with the photosensitive resin layer was combined with the coated protective film that had been prepared in the above, with the photosensitive resin layer of the former being in contact with the substance transfer-preventing layer of the latter, and pressed by the use of a roller to produce a photosensitive resin printing plate material.

The thus-produced, photosensitive resin printing plate material was set in FX400-AP (Toray Engineering's photomechanical processor), and imagewise exposed to semiconductor laser beams (wavelength 830 nm, beam diameter 20 μm , energy 800 mJ/cm²) through the protective film to form an image in the photocoloring layer. The optical density of the photocolored part of the layer was 2.8. After one week, the optical density of the photocolored part was still 2.8.

Next, using an exposing unit equipped with 10 chemical UV lamps (Mitsubishi Electric's FL20SBL-360), this was exposed to UV rays for 2 minutes through the photocolored layer. The distance between the printing plate material to be exposed and the light source was 60 mm. The edges of the printing plate material were covered with a light-shielding film to protect them from being exposed.

After exposed, the protective film was peeled off, and the printing plate material was developed with water at 25°C for 1 minute, using a brush-type developing unit, to thereby wash away the non-crosslinked part of the photosensitive resin layer. Thus was obtained a photosensitive resin printing plate having a relief image formed thereon. This is usable for relief printing.

Example 2:

In the same manner as in Example 1, a photosensitive resin printing plate material was produced in which, however, the substance transfer-preventing layer was not provided.

Also in the same manner as in Example 1, this photosensitive resin printing plate material was processed to form a photocolored image in the photocoloring layer. The image area had an optical density of 2.5. After 1 week, its optical density lowered to 1.6. This will be because the substances in the photosensitive resin layer in this printing plate material would have moved while the printing plate material was

stored.

Also in the same manner as in Example 1, the photosensitive resin layer of this printing plate material was exposed to UV rays via the photocolored layer, then the protective film was removed, and the thus-exposed resin layer was developed by brushing in water. A photosensitive resin printing plate having a relief image formed thereon was thus obtained.

Example 3:

In the same manner as in Example 1, a photocoloring layer was formed on a protective film.

Next, the photosensitive resin layer composition 2 (its amount is to form a photosensitive layer having a thickness of 1.7 mm) was put between a support film of polyethylene terephthalate (having a thickness of 125 μm and coated with a polyester adhesive) and the protective film coated with the photocoloring layer, and these were pressed by the use of a presser heated at 80°C. In the photosensitive resin printing plate material thus produced, the photocoloring layer and the photosensitive resin layer are in contact with each other.

Also in the same manner as in Example 1, the thus-produced, photosensitive resin printing plate material was exposed to form an image in the photocoloring layer.

Next, using the same exposing unit as in Example 1 equipped with 10 chemical UV lamps, this was exposed to UV rays

for 2 minutes first through the support, and then for 5 minutes through the thermocolored layer. Its edges were covered with a light-shielding film to protect them from being exposed.

After exposed, the protective film was peeled off, and the printing plate material was developed with water at 40°C for 7 minutes, using a brush-type developing unit, to thereby wash away the non-crosslinked part of the photosensitive resin layer. Thus was obtained a photosensitive resin printing plate having a relief image formed thereon. This is usable for flexographic printing.

Example 4:

The composition containing a thermal color former and a developer of the photocoloring layer composition 2 was applied onto a protective film of polyethylene terephthalate having a thickness of 12 μm , using a bar coater, and then dried to form a layer having a thickness of 12 μm . Next, the composition containing a photothermal-transforming substance of the composition 2 was applied thereonto, also using a bar coater, and then dried to form thereon another layer having a thickness of 8 μm . Thus coated, the film had an optical density of 0.5. This was further coated with the substance transfer-preventing layer composition, using a bar coater, then dried, and exposed to an ultra-high-pressure mercury lamp for 30 seconds. Thus photocured, the substance transfer-preventing layer formed had a thickness of 14 μm .

Next, the photosensitive resin layer composition 1 was cast onto a steel sheet support (thickness 100 μm) coated with an epoxy adhesive, and dried at 60°C for 3 hours to form thereon a photosensitive resin layer having a dry thickness of 650 μm .

The steel sheet support thus coated with the photosensitive resin layer was combined with the coated protective film that had been prepared in the above, with the photosensitive resin layer of the former being in contact with the substance transfer-preventing layer of the latter, and pressed by the use of a roller to produce a photosensitive resin printing plate material.

The thus-produced, photosensitive resin printing plate material was set in FX400-AP (Toray Engineering's photomechanical processor), and imagewise exposed to semiconductor laser beams (wavelength 830 nm, beam diameter 20 μm , energy 800 mJ/cm²) through the protective film to form an image in the photocoloring layer. The optical density of the photocolored part of the layer was 2.9. After one week, the optical density of the photocolored part was still 2.9.

Next, using an exposing unit equipped with 10 chemical UV lamps (Mitsubishi Electric's FL20SBL-360), this was exposed to UV rays for 2 minutes through the photocolored layer. The distance between the printing plate material to be exposed and the light source was 60 mm. The edges of the printing plate material were covered with a light-shielding film to protect

them from being exposed.

After exposed, the protective film was peeled off, and the printing plate material was developed with water at 25°C for 1 minute, using a brush-type developing unit, to thereby wash away the non-crosslinked part of the photosensitive resin layer. Thus was obtained a photosensitive resin printing plate having a relief image formed thereon. This is usable for relief printing.

Example 5:

The composition containing a thermal color former and a developer of the photocoloring layer composition 2 was applied onto a protective film of polyethylene terephthalate having a thickness of 12 μm , using a bar coater, and then dried to form a layer having a thickness of 8 μm . Next, the composition containing a photothermal-transforming substance of the composition 2 was applied thereonto, also using a bar coater, and then dried to form thereon another layer having a thickness of 2 μm . Thus coated, the film had an optical density of 0.4.

Next, the photosensitive resin layer composition 1 was cast onto a support film of polyethylene terephthalate (thickness 250 μm) coated with a polyester adhesive, and dried at 60°C for 3 hours to form thereon a photosensitive resin layer having a dry thickness of 650 μm .

The support film thus coated with the photosensitive resin layer was combined with the coated protective film that

had been prepared in the above, with the photosensitive resin layer of the former being in contact with the photocoloring layer of the latter, and pressed by the use of a roller to produce a photosensitive resin printing plate material.

The thus-produced, photosensitive resin printing plate material was set in FX400-AP (Toray Engineering's photomechanical processor), and imagewise exposed to semiconductor laser beams (wavelength 830 nm, beam diameter 20 μm , energy 800 mJ/cm²) through the protective film to form an image in the thermocoloring layer. The optical density of the thermocolored part of the layer was 2.6. After one week, the optical density of the photocolored part was 1.7.

Next, using an exposing unit equipped with 10 chemical UV lamps (Mitsubishi Electric's FL20SBL-360), this was exposed to UV rays for 2 minutes through the thermocolored layer. The distance between the printing plate material to be exposed and the light source was 60 mm. The edges of the printing plate material were covered with a light-shielding film to protect them from being exposed.

After exposed, the protective film was peeled off, and the printing plate material was developed with water at 25°C for 1 minute, using a brush-type developing unit, to thereby wash away the non-crosslinked part of the photosensitive resin layer. Thus was obtained a photosensitive resin printing plate having a relief image formed thereon. This is usable for relief

printing.

Example 6:

In the same manner as in Example 5, a photocoloring layer was formed on a protective film.

Next, the photosensitive resin layer composition 2 (its amount is to form a photosensitive layer having a thickness of 1.7 mm) was put between a support film of polyethylene terephthalate (having a thickness of 125 μ m and coated with a polyester adhesive) and the protective film coated with the thermocoloring layer and with the photothermal-transforming substance layer thereon, and these were pressed by the use of a presser heated at 80°C to complete a photosensitive resin printing plate material.

The thus-produced, photosensitive resin printing plate material was exposed to form an image in the thermocoloring layer, in the same manner as in Example 1.

Next, using the same exposing unit as in Example 5 equipped with 10 chemical UV lamps, this was exposed to UV rays for 2 minutes first through the support, and then for 5 minutes through the thermocolored layer. Its edges were covered with a light-shielding film to protect them from being exposed.

After exposed, the protective film was peeled off, and the printing plate material was developed with water at 40°C for 7 minutes, using a brush-type developing unit, to thereby wash away the non-crosslinked part of the photosensitive resin

layer. Thus was obtained a photosensitive resin printing plate having a relief image formed thereon. This is usable for flexographic printing.

Example 7:

The composition containing a photothermal-transforming substance of the photocoloring layer composition 2 was applied onto a protective film of polyethylene terephthalate having a thickness of 12 μm , using a bar coater, and then dried to form a layer having a thickness of 2 μm . Next, the composition containing a thermal color former and a developer of the composition 2 was applied thereonto, also using a bar coater, and then dried to form thereon another layer having a thickness of 8 μm . The protective film was thus coated with a photocoloring layer of the two layers formed thereon. Thus coated, this had an optical density of 0.4.

Next, the photosensitive resin layer composition 1 was cast onto a support film of polyethylene terephthalate (thickness 250 μm) coated with a polyester adhesive, and dried at 60°C for 3 hours to form thereon a photosensitive resin layer having a dry thickness of 650 μm .

The support film thus coated with the photosensitive resin layer was combined with the coated protective film that had been prepared in the above, with the photosensitive resin layer of the former being in contact with the photocoloring layer of the latter, and pressed by the use of a roller to produce

a photosensitive resin printing plate material.

The thus-produced, photosensitive resin printing plate material was set in FX400-AP (Toray Engineering's photomechanical processor), and imagewise exposed to semiconductor laser beams (wavelength 830 nm, beam diameter 20 μm , energy 800 mJ/cm²) through the protective film to form an image in the thermocoloring layer. The optical density of the thermocolored part of the layer was 2.6.

Next, using the same exposing unit as in Example 1 equipped with 10 chemical UV lamps, this was exposed to UV rays for 2 minutes through the thermocolored layer. The distance between the printing plate material to be exposed and the light source was 60 mm. The edges of the printing plate material were covered with a light-shielding film to protect them from being exposed.

After exposed, the protective film was peeled off, and the printing plate material was developed with water at 25°C for 1 minute, using a brush-type developing unit, to thereby wash away the non-crosslinked part of the photosensitive resin layer. Thus was obtained a photosensitive resin printing plate having a relief image formed thereon. This is usable for relief printing.

Comparative Example 1:

A photosensitive resin printing plate material was produced in the same manner as in Example 5. In this, however,

the photocoloring layer did not have a photothermal-transforming substance layer.

The photosensitive resin printing plate material was set in FX400-AP (Toray Engineering's photomechanical processor), and imagewise exposed to semiconductor laser beams (wavelength 830 nm, beam diameter 20 μm , energy 800 mJ/cm²) through the protective film. In this, however, an image was not formed in the thermocoloring layer.

Probably, in this, the thermal color former was not heated to form a color, since a photothermal-transforming substance layer was not therein.

6. The photosensitive resin printing plate material as claimed in any of claims 1 to 5, wherein the photosensitive resin layer is photocured when exposed to light having a wavelength of from 300 to 450 nm, and its thickness falls between 0.1 mm and 10 mm.

7. The photosensitive resin printing plate material as claimed in any of claims 1 to 6, wherein the photosensitive resin layer contains at least one polymer selected from a group consisting of partially-saponified polyvinyl acetate, polyamide resin, polyvinyl alcohol, and their modified derivatives, at least along with an ethylenic unsaturated compound and a photopolymerization initiator.

8. The photosensitive resin printing plate material as claimed in any of claims 1 to 7, which has a substance transfer-preventing layer between the photosensitive resin layer and the photocoloring layer.

9. The photosensitive resin printing plate material as claimed in claim 8, wherein the substance transfer-preventing layer contains a binder resin selected from hydrophilic resins, hydrophobic resins and UV-curable resins.

10. A method for producing a photosensitive resin printing plate, which comprises at least a step of forming an image in a photocoloring layer, a step of exposing a photosensitive resin layer to light through the photocoloring layer, and a step of developing the photosensitive resin layer.

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11. A method for producing a photosensitive resin printing plate, wherein a photosensitive resin printing plate material having a photosensitive resin layer and a photocoloring layer laminated on a support is imagewise exposed to light having a wavelength of from 450 to 1500 nm whereby only the exposed site of the photocoloring layer is colored to form an image in the layer, then this is further exposed to light having a wavelength of from 300 to 450 nm via the image-having, photocolored layer to thereby imagewise cure the photosensitive resin layer, and thereafter this is processed with a developer so as to remove the resin layer except the cured resin to thereby form a relief image on the support.

ABSTRACT

Disclosed is a photosensitive resin printing plate material, which comprises at least a support, a photosensitive resin layer and a photocoloring layer, and in which the photocoloring layer is UV-transmissive before colored, and is colored through exposure to light having a wavelength of from 450 to 1500 nm to be substantially UV-non-transmissive. This is transparent and can reproduce any fine relief, not requiring an original picture film.

- ☐ Original Application
☒ PCT National Application
U.S. Designated Office
☐ Continuation or Divisional Application
☐ Continuation-in-Part Application

**COMBINED DECLARATION,
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As a below named inventor, I hereby declare that:

My residence, post office address and citizenship are as stated below next to my name,

I believe I am the original, first and sole inventor (if only one name is listed below) or an original, first and joint inventor (if plural names are listed below) of the subject matter which is claimed and for which a patent is sought on the invention entitled PHOTOSENSITIVE RESIN PRINT PLATE MATERIAL AND PRODUCTION METHOD FOR PHOTOSENSITIVE RESIN PRINT PLATE

which is described in the specification and claims

- ☐ attached hereto.
☐ filed on _____
Application Serial No. _____
and was amended on _____
(if applicable)

☒ which is described in International Application No. **PCT/JP00/08356**

filed November 28, 2000 and as amended on _____

_____ (if any),
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I hereby state that I have reviewed and understand the contents of the above-identified specification, including the claims, as amended by any amendment referred to above.

I acknowledge the duty to disclose information which is material to the examination of this application in accordance with Title 37, Code of Federal Regulations, §1.56.

I do not know and do not believe that this invention was ever known or used in the United States before my or our invention thereof or patented or described in any printed publication in any country before my or our invention thereof or more than one year prior to this application or said international application, or in public use or on sale in the United States of America more than one year prior to this application or said international application, or that the invention has been patented or made the subject of an inventor's certificate issued before the date of this application or said international application in any country foreign to the United States of America on an application filed by me or my legal representatives or assigns more than twelve months prior to this application or said international application, or that any application for patent or inventor's certificate on this invention has been filed in any country foreign to the United States of America prior to this application or said international application by me or my legal representatives or assigns except as identified below.

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(Page 2)

Attorney Docket No. 1265-01

I hereby claim foreign priority benefits under Title 35, United States Code, §119(a)-(d) or §365(b) of any foreign application(s) for patent or inventor's certificate, or §365(a) of any PCT International Application which designated at least one country other than the United States of America, listed below and have also identified below any foreign application(s) for patent or inventor's certificate, or of any PCT International Application having a filing date before that of the application on which priority is claimed:

Number	Country	Date of Filing (day,month,year)	Priority Claimed
11/350793	Japan	09 December, 1999	<input checked="" type="checkbox"/> yes <input type="checkbox"/> no
2000/5044	Japan	13 January, 2000	<input checked="" type="checkbox"/> yes <input type="checkbox"/> no
			<input type="checkbox"/> yes <input type="checkbox"/> no
			<input type="checkbox"/> yes <input type="checkbox"/> no
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(Application Serial No.)

(Filing Date)

(Status)(patented,pending,abandoned)

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(Filing Date)

(Status)(patented,pending,abandoned)

POWER OF ATTORNEY: As a named inventor, I hereby appoint the registered attorneys listed under Customer No. 022469 and the following registered attorneys to prosecute this application and transact all business in the United States Patent and Trademark Office connected therewith:

T. Daniel Christenbury Reg. No. 31,750
 Guy T. Donatiello Reg. No. 33,167
 Paul A. Taufer Reg. No. 35,703
 James A. Drobile Reg. No. 19,690
 Austin R. Miller Reg. No. 16,602
 Gerard J. Weiser Reg. No. 19,763
 Joan T. Kluger Reg. No. 38,940

Patrick J. Farley Reg. No. 42,524
 Michael A. Patane Reg. No. 42,982
 David A. Sasso Reg. No. 43,084
 Robert A. McKinley Reg. No. 43,793
 Sharon Fenick Reg. No. 45,269
 Stewart M. Wiener Reg. No. 46,201

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SEND CORRESPONDENCE TO:

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Philadelphia, PA 19103

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(215) 563-1810

(Page 3)

I hereby petition for grant of a United States Letters Patent on this invention.

I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

1. FULL NAME OF SOLE OR FIRST INVENTOR Shinji Tanaka		INVENTOR'S SIGNATURE <i>Shinji Tanaka</i>		DATE August 1, 2001	
RESIDENCE Okazaki Japan		CITIZENSHIP Japanese			
POST OFFICE ADDRESS Matsu-3, Toray Terasuhouse, 145Aza Motonagare, Tsutsubari-cho, Okazaki-shi, Aichi 444-0932 Japan					
2. FULL NAME OF JOINT INVENTOR, IF ANY Katsuhiro Uehara			INVENTOR'S SIGNATURE <i>Katsuhiro Uehara</i>		DATE August 1, 2001
RESIDENCE Tokyo Japan			CITIZENSHIP Japanese		
POST OFFICE ADDRESS 2-28-18-311, Sangenjaya, Setagaya-ku, Tokyo 154-0024 Japan					
3. FULL NAME OF ADDITIONAL JOINT INVENTOR, IF ANY			INVENTOR'S SIGNATURE		DATE
RESIDENCE			CITIZENSHIP		
POST OFFICE ADDRESS					
4. FULL NAME OF ADDITIONAL JOINT INVENTOR, IF ANY			INVENTOR'S SIGNATURE		DATE
RESIDENCE			CITIZENSHIP		
POST OFFICE ADDRESS					
5. FULL NAME OF ADDITIONAL JOINT INVENTOR, IF ANY			INVENTOR'S SIGNATURE		DATE
RESIDENCE			CITIZENSHIP		
POST OFFICE ADDRESS					
6. FULL NAME OF ADDITIONAL JOINT INVENTOR, IF ANY			INVENTOR'S SIGNATURE		DATE
RESIDENCE			CITIZENSHIP		
POST OFFICE ADDRESS					
7. FULL NAME OF ADDITIONAL JOINT INVENTOR, IF ANY			INVENTOR'S SIGNATURE		DATE
RESIDENCE			CITIZENSHIP		
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